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For: Plasma Processing Method and Apparatus Thereof

VERIFICATION OF TRANSLATION

Honorable Commissioner of Patents and Trademarks

Washington, D.C. 20231,

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- (2) that I translated the above-identified International Application from Japanese to English;
- (3) that the attached English translation is a true and correct translation of the above-identified International Application to the best of my knowledge and belief; and
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Date: July 19, 2006



Konomi MACHIDA

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DESCRIPTION

PLASMA PROCESSING METHOD AND APPARATUS THEREOF

Technical Field

[0001] The present invention is mainly applied to various surface treatments or gas decomposition processes such as those of, in the case where application of a coating composition or printing is performed on a resin such as polyethylene, polypropylene, polyester (PET), or PTFE (polytetrafluoroethylene), modifying the water repellent property of the surface to the water-attracting property, washing away organics adhering to the surface of glass, ceramics, a metal, a semiconductor, or the like, conducting disinfection or sterilization, and performing an etching process, and more particularly to a plasma treating method of the corona discharge type in which a surface treatment such as modification is conducted by irradiating the surface of a workpiece with excited species such as excited molecules, radicals, or ions which are generated as a result of molecular dissociation due to plasma produced by a corona discharge, and an apparatus therefor.

Background Art

[0002] A plasma surface treating method of the corona discharge type has an advantage that the use of an ignition gas such as helium, argon, or hydrogen which is required in the case of a plasma surface treating method of

the glow discharge type at atmospheric pressure can be omitted, and improvement of the safety in use and reduction of the treatment cost due to a reduced gas consumption can be realized. Therefore, the method is often used in surface treatments such as surface modification.

[0003] Important factors in determining the treatment performance and treatment efficiency of this kind of the plasma surface treating method of the corona discharge type are the amount, area, and uniformity of irradiation of excited species including plasma produced by a corona discharge, to the surface of a workpiece. As means for attaining these important factors, conventionally, a pair of discharge electrodes are placed in an opposing state, a sinusoidal AC voltage is applied between the electrodes to generate a corona discharge between the electrodes, and a gas such as air is flown in an area of the discharge (for example, see Patent Reference 1).

Patent Reference 1: Japanese Patent Application Laying-Open No. 2001-293363 (Fig. 4)

Disclosure of the Invention

Problems that the Invention is to Solve

[0004] In the above-described conventional plasma surface treating method of the corona discharge type, however, one transformer is disposed for one discharging unit having a pair of discharge electrodes, and there is a problem in

that, when a wide range is to be surface-treated, transformers the number of which is equal to that of placed discharging units must be equipped.

[0005] The invention has been conducted in view of the above-mentioned circumstances. It is an object of the invention to provide a plasma treating method in which an electric power to be supplied to plural discharging units is covered by one transformer, and an apparatus therefor.

Means for Solving the Problems

[0006] In order to attain the object, a plasma treating method of claim 1 of the invention is a plasma treating method in which a pulse voltage is applied between opposing discharge electrodes to produce a corona discharge between pointed ends of the discharge electrodes, and a surface of a workpiece is irradiated with excited species including plasma produced by the corona discharge, thereby treating the surface, wherein a secondary output of a transformer is branched to be supplied to discharge electrodes of different discharging units, whereby the corona discharge is generated between the discharge electrodes of the discharging units.

[0007] Furthermore, a plasma treating apparatus of claim 6 of the invention is a plasma treating apparatus in which a pulse voltage is applied to opposing discharge electrodes to produce a corona discharge between pointed ends of the

discharge electrodes, and a surface of a workpiece is irradiated with excited species including plasma produced by the corona discharge, thereby treating the surface, wherein an output circuit which is led out from one of secondary terminals of a transformer is branched, rectifiers are disposed in branch circuits, respectively, the branch circuits are connected to one discharge electrodes of different discharging units, another secondary terminal of the transformer is branched to be connected to other discharge electrodes of the different discharging units, and the corona discharge is generated between the discharge electrodes based on a pulse voltage which is applied between the discharge electrodes in each of the discharging units.

Effects of the Invention

[0008] According to the invention having the above configuration, the pulse voltage is supplied from one transformer to plural discharging units to cause a discharge. Even when plural discharging units are disposed in order to increase the amount and area of irradiation of excited species to the surface of the workpiece, only one transformer is required. Therefore, the size of the apparatus can be reduced, and the installation cost can be suppressed to a low level. Moreover, a corona discharge can be generated alternately in the pair of discharging units. Therefore,

the front and rear sides of the workpiece can be treated by the electricity supply from the same transformer.

[0009] In the above-described plasma treating method and apparatus of the corona discharge type, as the pulse voltage applied to the discharge electrodes, any one of a rectangular pulse voltage as set forth in claim 2, and a pulse voltage configured by plural pulsating waves which are obtained by full-wave rectifying an AC voltage as set forth in claim 3 may be used. In the case where the pulse voltage configured by pulsating waves is used, particularly, a special pulse voltage generation power source is not necessary, and a simple power source device configured by a combination of an AC power source of a commercial or ultrasonic region and rectifying elements such as diodes can be used. Therefore, it is possible to apply a pulse voltage of a desired period and duty, and realize a cost reduction of the apparatus.

[0010] In the case where, as set forth in claims 4 and 7, the pulse voltage is applied to the discharge electrodes in a state where a magnetic field is formed in vicinities of the pointed ends of the discharge electrodes, to generate a corona discharge between the electrodes, excited species including plasma produced by the corona discharge exist in the magnetic field. Therefore, the magnetic field applies a pushing force, i.e., the Lorentz force to

a charged particle in plasma moving in the magnetic field, and the excited species can be irradiated toward the surface of the workpiece vigorously and substantially uniformly over a wide area.

[0011] As the means for forming the magnetic field in the plasma treating apparatus of the corona discharge type, any one of means configured by a permanent magnet, a pair of magnetic members, and a pair of pole pieces in which a gap is formed between end faces as set forth in claim 8, and that configured by an electromagnet connected to a DC power source, a pair of magnetic members, and a pair of pole pieces in which a gap is formed between end faces as set forth in claim 9 may be used. In the case where a permanent magnet is used, lowering of the production cost and saving of the power consumption are enabled. By contrast, in the case where an electromagnet is used, the production cost and the power consumption are increased as compared with the case where a permanent magnet is used. However, the Lorentz force, and the irradiation force and irradiation diffusion range of the excited species including plasma can be controlled easily and arbitrarily in accordance with the surface configuration of the workpiece, or the like, by adjusting the magnetic flux density in the gap between the end faces of the pole pieces. Therefore, the shape applicability with respect to the workpiece can

be enhanced, and the treatment performance and treatment efficiency can be further improved.

[0012] In the invention, as set forth in claims 5 and 10, a reactive gas such as argon, nitrogen, or carbon dioxide gas, or air may be introduced between the discharge electrodes at atmospheric pressure or a vicinity of atmospheric pressure. According to the configuration, a flow of the gas causes excited species including plasma to be irradiated toward the surface of the workpiece, and the amount, area, and uniformity of irradiation to the surface of the workpiece can be attained. Moreover, the excitation gas flow is caused to be irradiated, by the pushing action force (Lorentz force) which is received from the magnetic field, whereby the invention can be used in various surface treatments.

Brief Description of the Drawings

[0013] [Fig. 1] Fig. 1 is a partially omitted longitudinal section front view showing an embodiment of the plasma treating apparatus of the invention.

[Fig. 2] Fig. 2 is a partially cutaway perspective view of the apparatus of Fig. 1.

Description of Reference Numerals

[0014] 4 ... discharge electrode, 6, 7 ... pole piece, 8 ... permanent magnet, 11 ... first electrode, 12 ... second electrode, 13 ... discharging unit, 15 ... transformer, 19,

20 ... rectifier, 18 ... branch circuit, M ... magnetic field forming means.

Best Mode for Carrying Out the Invention

[0015] Hereinafter, an embodiment of the invention will be described on the basis of the drawings.

Fig. 1 is a schematic longitudinal section front view showing an embodiment of a plasma surface treating apparatus to which the invention is applied, and Fig. 2 is a partially cutaway perspective view.

The plasma surface treating apparatus is configured by: a plate-like insulating member (3) in which many gas ejection holes (1) are disposed in a row, and a gas reservoir (2) where upper ends portions of the gas ejection holes communicate with each other is formed inside; discharge electrodes (4) which are supported on the plate-like insulating member (3); a pair of ceramics-made insulating spacers (5) which are formed in a state where the discharge electrodes (4) are interposed back and forth; pole pieces (6) (7) which are placed outside the ceramics-made insulating spacers (5), respectively; magnets (8) which are magnetically coupled and connected to the pole pieces (6) (7), respectively; coupling rods (9) which are made of a magnetic material, and which connect together upper end portions of the magnets (8); and a power source device (10) which applies a discharging voltage to the

discharge electrodes (4).

[0016] The discharge electrodes (4) are configured by: a first electrode (11) which is formed into a substantially L-like shape; and a substantially L-like second electrode (12) which is placed in a state where it opposes the first electrode (11). Each of the electrode (11) (12) is formed by a refractory metal such as tungsten or molybdenum.

[0017] The power source device (10) is configured by: an AC power source (14); a transformer (15) which boosts an AC current; and pulse voltage applying means (16) consisting of a full-wave rectifier circuit which is placed on the secondary side of the transformer (15), and which is formed by removing away capacitors from a voltage doubler rectifier circuit. An output circuit (17) which electrically connects one of the secondary terminals of the transformer (15) to the first electrode (11) of a discharging unit (13) is branched and formed, and branch output circuit (17) are connected to the first electrodes (11) of different discharging units, respectively. In second output circuits (18) which electrically connect the other secondary terminal of the transformer (15) to the second electrodes (12), high-voltage rectifying diodes (19) (20) are respectively interposed. In this case, the high-voltage rectifying diode (19) and the high-voltage rectifying diode (20) are placed while their flow direc-

tions are opposite to each other, so that, in one of the discharging units, a discharge is started when the second electrode (12) outputs a high voltage with respect to the first electrode (11), and, in the other discharging unit, a discharge is started when the second electrode (12) outputs a low voltage with respect to the first electrode (11). Namely, as a pulse voltage, the pulse voltage applying means (16) applies alternately positive- and negative-voltage side pulsating waves which are respectively half-wave rectified. A corona discharge is produced between the pointed ends of the first electrode (11) and the second electrode (12), and excited species including plasma is produced by the corona discharge.

[0018] In the power source device (10), the AC power source of 50 Hz to 100 KHz is boosted by the transformer (15) to a sinusoidal wave having a peak value V_p of 5 to 15 KV. The boosted sinusoidal wave is converted to a DC pulsating wave having a peak value V_p of 5 to 15 KV. The positive voltage portions (DC) are applied between the first electrode (11) and the second electrode (12) of one discharging unit k , and the negative voltage portions are applied between the first electrode (11) and the second electrode (12) of the other discharging unit, whereby, while setting a sum of the ON period and the OFF period as one period T , pulse voltages having a pulse frequency $(1/T)$ of 10 to 200

Hz and a pulse duty of 10 to 100% are alternately generated.

[0019] Magnetic field forming means for forming a magnetic field extending along a horizontal plane perpendicular to a gas flow in which charged particles in plasma produced by the corona discharge exist is disposed in positions proximal to the pointed ends of the discharge electrodes (4). The magnetic field forming means is configured by: the permanent magnets (8) which are placed above basal end portions of the discharge electrodes (4); a pair of soft magnetic members which are made of pure iron or the like, which are connected to the both N and S poles of the permanent magnets (8), and which elongate to the vicinities of the pointed ends of the pair of discharge electrodes (4); and a pair of pole pieces (6) (7) which are made of pure iron or the like, which are integrally continuous to the tip ends of the soft magnetic members, and which oppose each other with the pointed ends of the discharge electrodes (4) therebetween to form a magnetic field forming gap between the opposing end faces. In accordance that a charged particle in plasma moves in the magnetic field formed in the gap between the end faces of the pole pieces (6) (7) in the magnetic field forming means, the charged particle undergoes a pushing force, i.e., the Lorentz force, and excited species including plasma are irra-

diated toward the surface of the workpiece as indicated by the arrow X in Figs. 1 and 2.

[0020] When the charge of a particle is Q , the velocity is v , and the magnetic flux density between the end faces of the pole pieces is B , the Lorentz force F is:

$$F = Qv \times B$$

The force acts perpendicularly to the velocity vector of the charged particle, whereby excited species including plasma are pushed and irradiated in the direction of the arrow X.

[0021] A reactive gas such as argon, nitrogen, oxygen, or carbon dioxide gas, or air is introduced between the pair of discharge electrodes at the atmospheric pressure or a vicinity of the atmospheric pressure, from the gas ejection holes (1) formed in the plate-like insulating member (3), and an excitation gas flow including plasma is irradiated toward the surface of the workpiece by the Lorentz force received from the magnetic field. Therefore, the applicability of the surface treatment can be expanded.

[0022] In the thus configured plasma surface treating apparatus of the corona discharge type, a magnetic field configured by an effective magnetic flux and a leakage magnetic flux is formed in the gap between the end faces of the pole pieces (6) (7) which are connected to the N

and S poles of the permanent magnet (8) via the soft magnetic members. In this state, the output rectified by the above-mentioned power source device (10) applies a positive or negative pulse voltage of a pulse frequency of 10 to 200 Hz between the first electrode (11) and the second electrode (12) to alternately produce a corona discharge between the pointed ends of the electrodes (11) (12). As a result, excited species including plasma produced by the corona discharge exist in the magnetic field. A force in the direction of the arrow X which is perpendicular to the magnetic field is applied to the excited species including plasma by the above-mentioned Lorentz force F that is received from the magnetic field by charged particles in the plasma moving in the magnetic field.

[0023] In the invention, a positive or negative pulse voltage configured by plural pulsating waves obtained by rectifying an AC voltage is used in the first electrode (11) and second electrodes (12) which constitute the pair of discharge electrodes (4). Therefore, a special pulse voltage generating power source such as a multivibrator, a Schmidt trigger circuit, or a blocking oscillator is not required, and a pulse voltage of a desired period and duty can be applied by using a simple power source device configured by a combination of a commercial AC power source or an ultrasonic power source and rectifying elements such

as diodes. Moreover, the permanent magnet (8) which can be produced at a low cost, and which does not consume an electric power is used as the magnetic field forming means.

As a result, the introduction cost and running cost of the whole apparatus can be reduced.

[0024] In the embodiment, the permanent magnet (8) is used as the magnetic field forming means (M). Alternatively, an electromagnet may be used as the magnetic field forming means. When an electromagnet is used as the magnetic field forming means (M) as described above, the Lorentz force F can be controlled, and the force which is loaded on excited species including plasma, and which is perpendicular to the magnetic field can be adjusted.

[0025] In the embodiment, the magnetic field is formed between the end faces opposing each other across the pointed ends of the discharge electrodes (4), and a reactive gas or air is ejected between the end faces. Alternatively, only one of the magnetic field formation and the gas introduction may be employed.

[0026] In the embodiment, the pulse voltage applying means configured by the AC power source and the rectifier circuit for generating a pulse voltage formed by plural pulsating waves which are obtained by full-wave rectifying the AC voltage has been described. Alternatively, the pulse voltage applying means may be a pulse voltage gener-

ating power source which generates a rectangular pulse voltage.

Industrial Applicability

[0027] The invention can be mainly applied to various surface treatments such as those of, in the case where application of a coating composition or printing is performed on a resin such as polyethylene, polypropylene, polyester (PET), or PTFE (polytetrafluoroethylene), modifying the water repellent property of the surface to the water-attracting property, washing away organics adhering to the surface of glass, ceramics, a metal, a semiconductor, or the like, conducting disinfection or sterilization, and performing an etching process, or a gas decomposition process using molecular dissociation due to plasma produced by a corona discharge.